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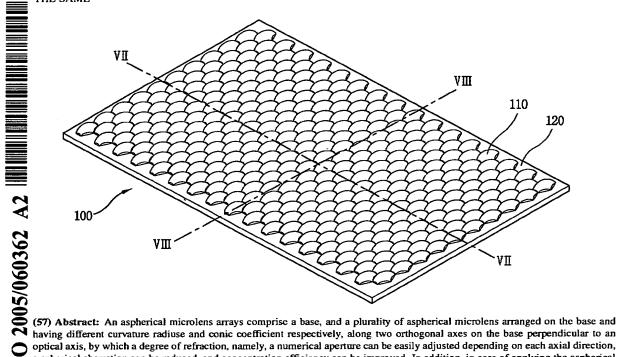
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(54) Title: ASPHERICAL MICROLENS ARRAYS AND FABRICATION METHOD THEREOF AND APPLICATIONS USING THE SAME



optical axis, by which a degree of refraction, namely, a numerical aperture can be easily adjusted depending on each axial direction, a spherical aberration can be reduced, and concentration efficiency can be improved. In addition, in case of applying the aspherical microlens arrays to a projection screen, an image sensor, or the like, it is advantageous to improve sensitivity and resolution thereof.

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